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IN THE UNITED STATES
PATENT AND TRADEMARK OFFICE

In re Patent Application of:

Inventor:	Chen et al	Confirmation No:	8388
Serial No.:	10/769,385	Examiner:	Pamela Schwartz
Filed:	Jan 30, 2004	Group Art Unit:	1774
Title:	Surface Modification Of Silica In An Aqueous Environment		

Commissioner for Patents
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Alexandria VA 22313-1450

RESPONSE TO RESTRICTION REQUIREMENT

In response to your Office Action/Restriction Requirement dated November 25, 2005; Applicants affirm the election with traverse of **Group I (Claims 1-22)** Group II (Claims 23-28) and Group III (Claims 29-37 are hereby withdrawn.

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Respectfully submitted,

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I hereby certify that this correspondence is being deposited on the date indicated below with the United States Postal Service as first class mail in an envelope addressed to: Commissioner for Patents, P O Box 1450, Alexandria, VA 22313.

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